

Plasma physics

2023 winter s. 2/1 , C+Ex

prof. Juraj Glosík, doc. Radek Plašil

- Glow discharge
- Arc discharge
- RF, μ W discharge

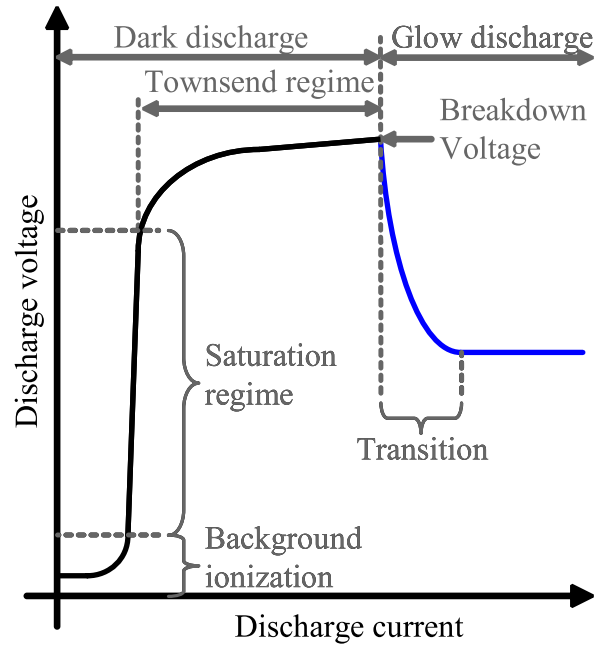


Townsend avalanche, Townsend breakdown

from previous class

$$n_e(x) = n_e(0)\exp(\bar{\alpha}x)$$

Townsend breakdown $\bar{\alpha}d \geq \ln(1 + \epsilon_i^{-1})$

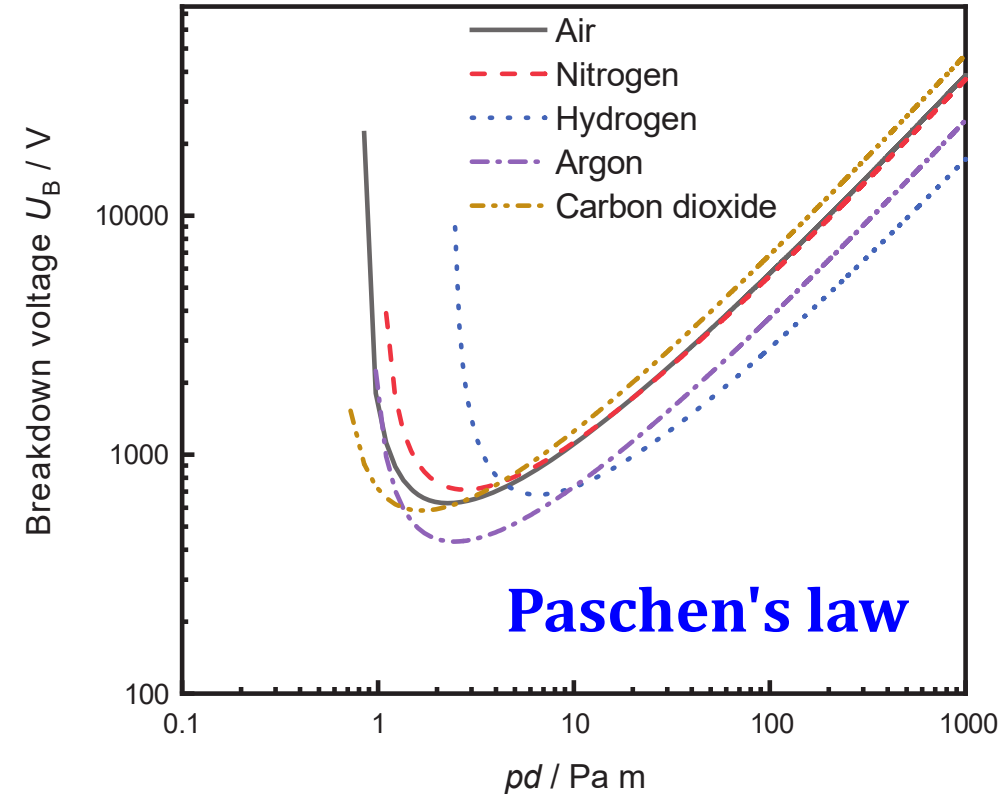


$$U_B(pd) = \frac{Bpd}{\ln \left[\frac{Apd}{\ln(1 + \epsilon_i^{-1})} \right]}$$

e ... Euler number

$$U_{B, \min} = \frac{eB}{A} \ln(1 + \epsilon_i^{-1})$$

$$(pd)_{\min} = \frac{e}{A} \ln(1 + \epsilon_i^{-1})$$



Ollegott K. et al. *Chem. Ing. Tech.* 92 2020 1.
doi: 10.1002/cite.202000075



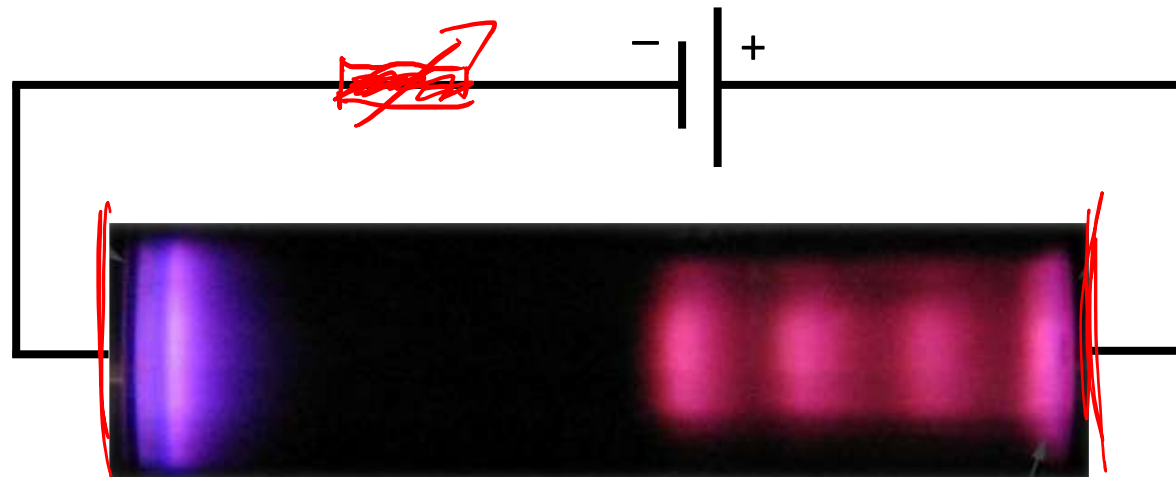
Glow discharge

{Czech: Doutnavý výboj}
{Slovak: Tlejúci výboj}

Townsend breakdown leads to glow discharge.

Typical glow discharge DC, 10 – 1000 Pa, 300 – 500 V, 0.1 – 100 mA

The reduced pressure increases the mean free path
so that electrons can be accelerated at a given length by a lower voltage. $U_B(pd)$



Glow discharge — Cathode layer

Aston dark space

secondary electrons with low energy ≈ 1 eV
no excitation or ionization, \approx one mean free path

Cathode glow

excitation by accelerated electrons and deexcitation
length depends on the gas and pressure

Cathode dark space / Crookes dark space

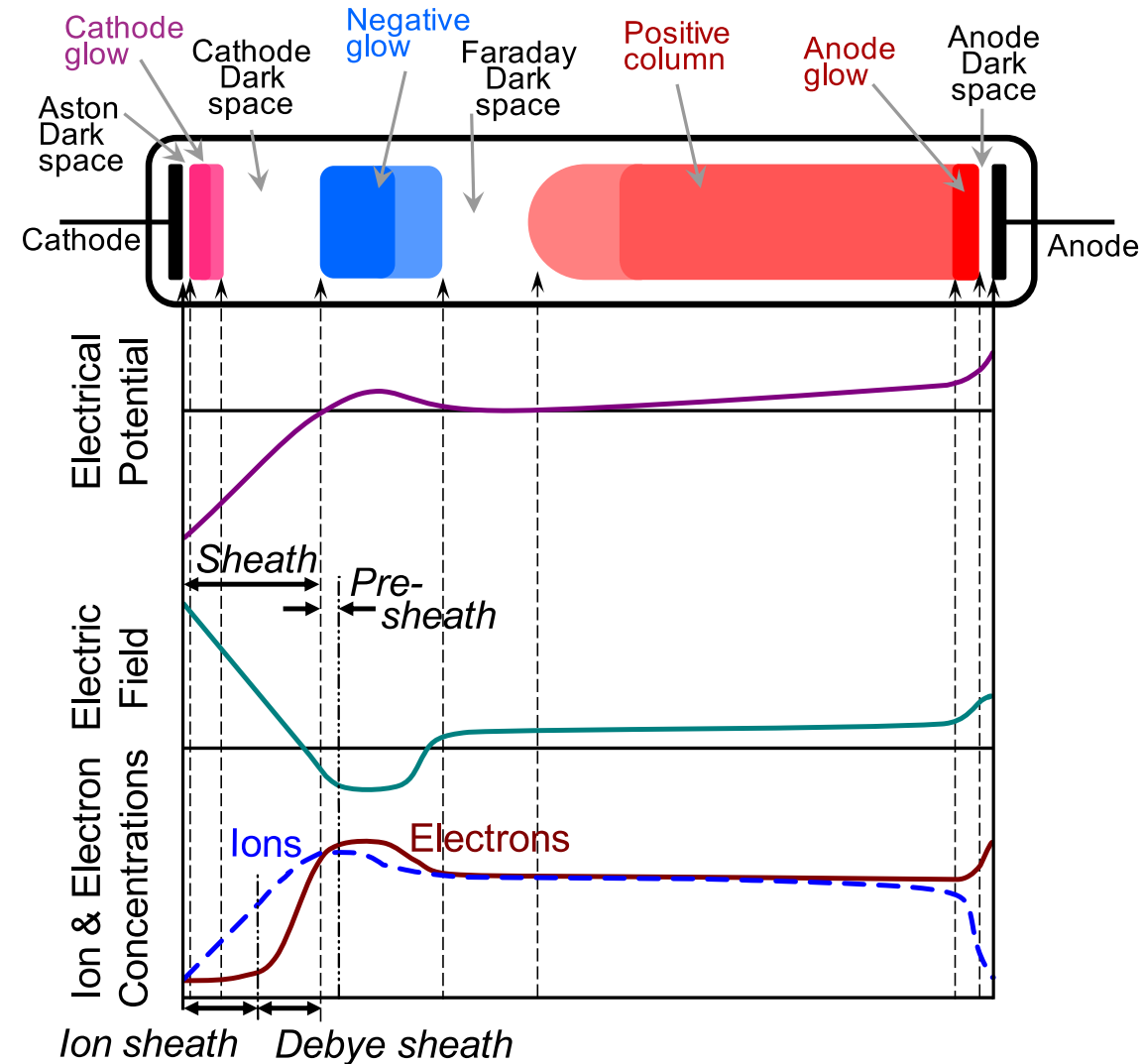
ionization by accelerated electrons
strong el. field separates charges \Rightarrow no recombination

Negative glow

accumulated slower electrons and ions
bremsstrahlung radiation (bluish)
typically brightest part of discharge

Faraday dark space

low electric field, low energy of electrons
slower electrons and ions \Rightarrow recombination



Glow discharge — Anode layer

Positive Column

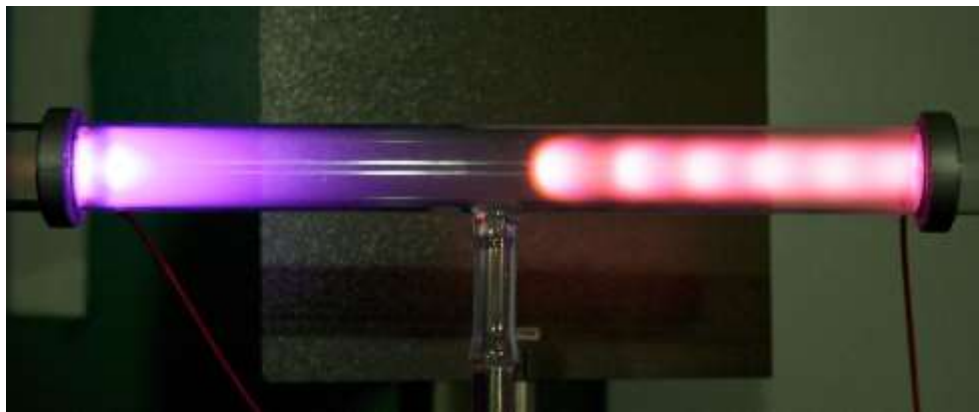
low electric field $\approx 1 \text{ V cm}^{-1}$
quasi-neutral plasma
electron drift velocity $<$ thermal velocity
striations (standing waves) v_e modulation

Anode glow

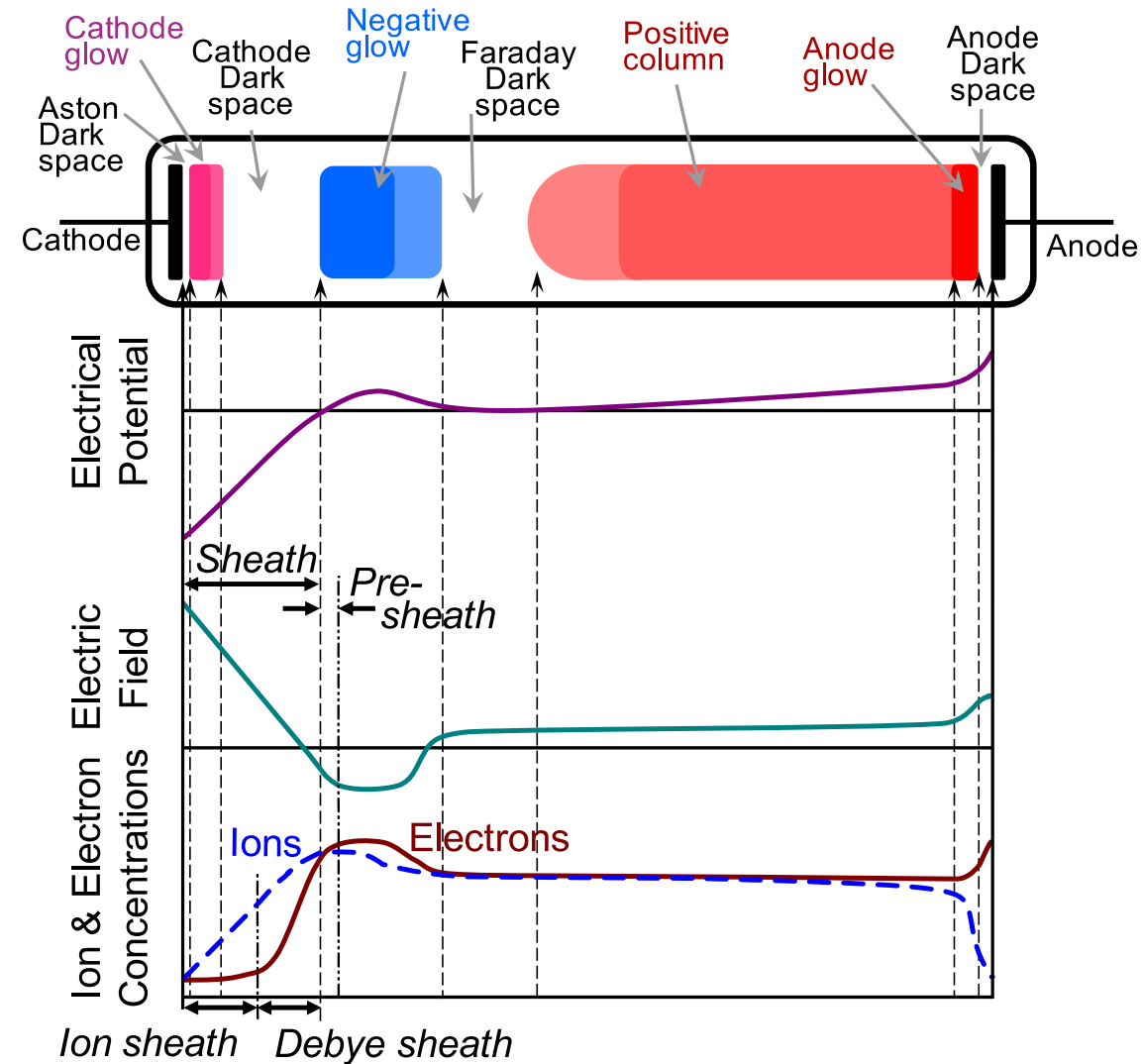
ions are repelled from anode \Rightarrow electric field
accelerated electrons excites neutrals

Anode dark space

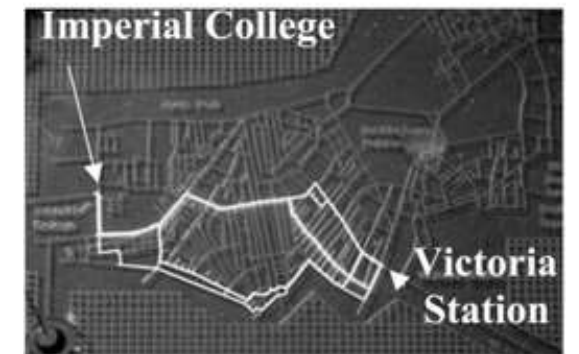
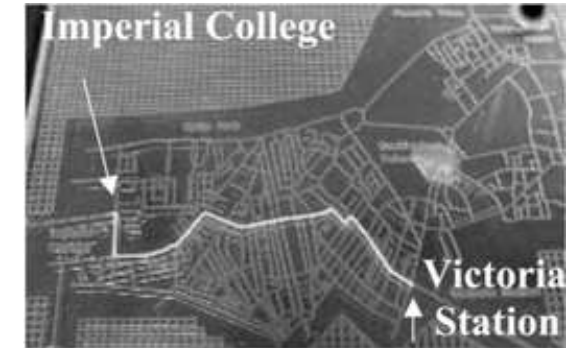
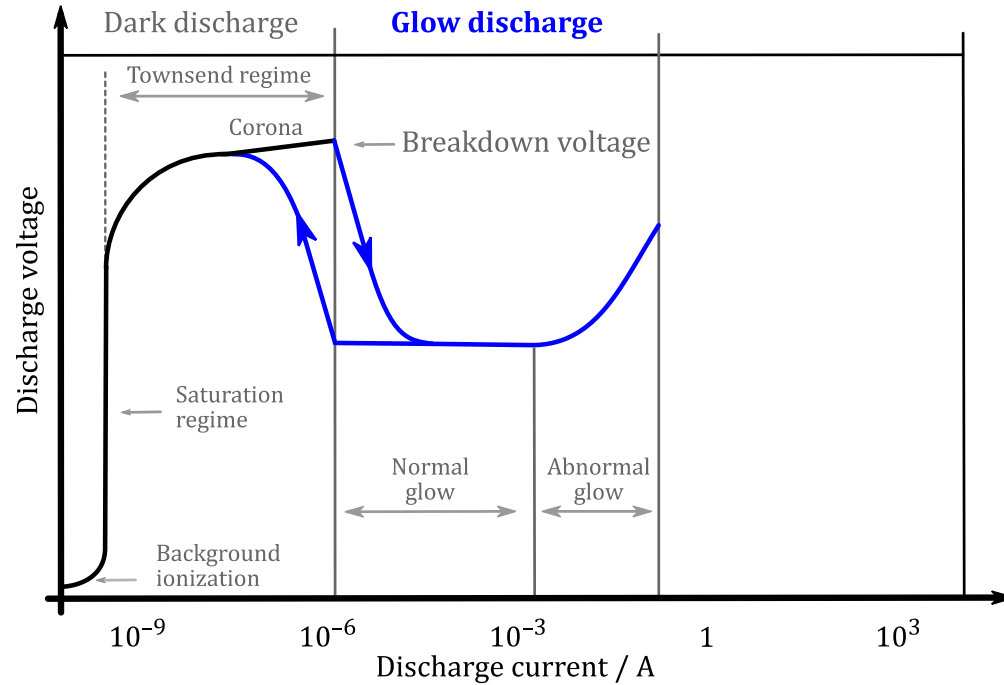
ionization by accelerated electrons, no recombination



Wikimedia Commons



Glow discharge applications



Applications:

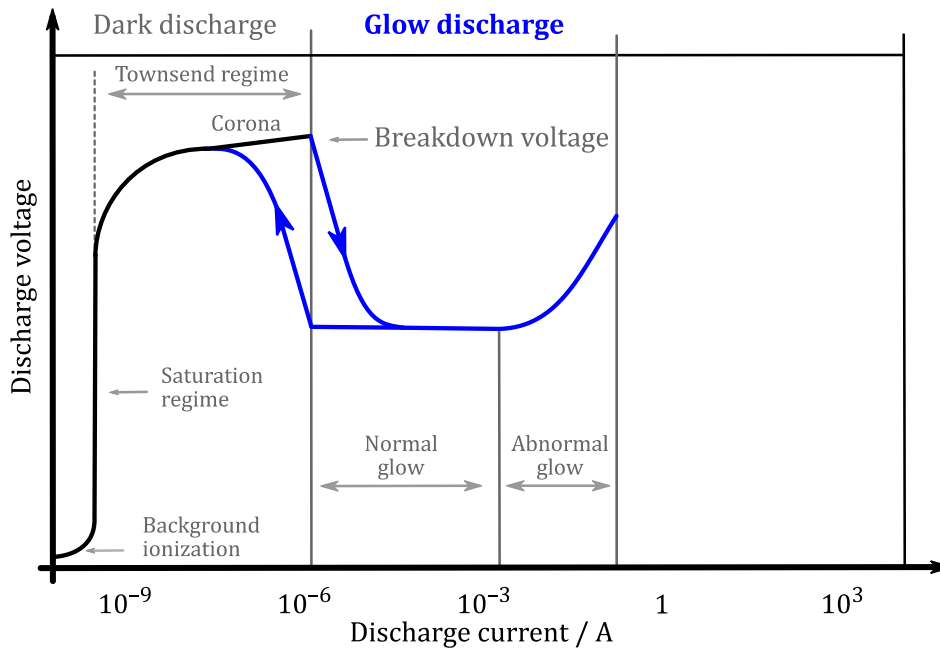
- Lightning
- Voltage-regulator tube
- Glow Discharge Mass Spectrometry (atomization)
- Surface modification (implanting ions, etching, cleaning)
- and many others

Dittrich P. S. *Lab on a Chip* 8 (2008) 1769.
doi: 10.1039/b816252m

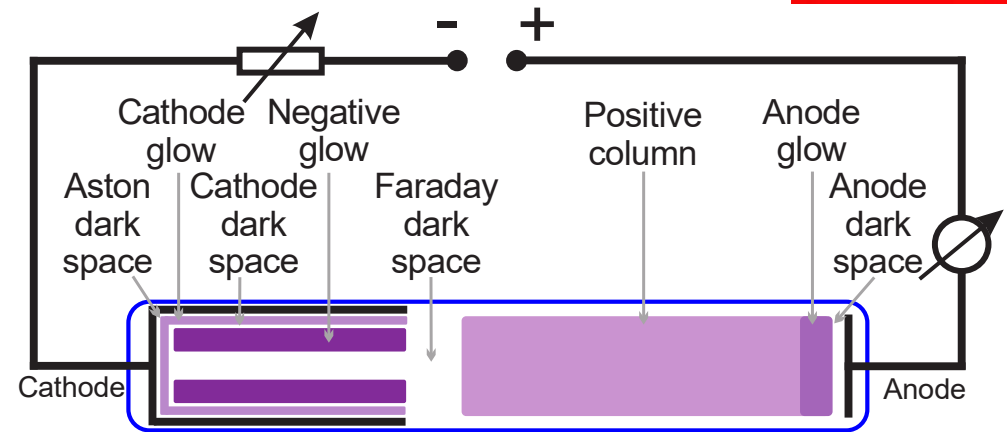


Abnormal glow discharge

is used in most industrial applications due to its higher current density (10 – 100 mA), higher ion energy and stability.



hollow cathode



Karatodorov S. I. *Dissertation thesis* (2017)
Bulgarian Academy of Sciences.

- longer path of electrons “pendulum effect”
- photoionization
- larger surface area \Rightarrow higher currents
- limited sputtering into the discharge tube



Arc discharge

Enhanced electron emission from metals

ϕ ... work function

Richardson–Dushman equation

Thermionic emission

$$j_{\text{therm}} = \lambda_R A_0 T^2 \exp\left(-\frac{\phi}{k_B T}\right) \quad A_0 = \frac{4\pi m_e k_B^2 q_e}{h^3}$$

(A m⁻²)

Schottky emission

$$j_{\text{Schottky}} = \lambda_R A_0 T^2 \exp\left(-\frac{(\phi - \Delta W)}{k_B T}\right)$$

(Field enhanced emission – tunneling)

barrier lowering $\Delta W = \sqrt{\frac{q_e^3 E}{4\pi \epsilon_0}}$

Cathodic arc spots, sputtering
(explosive emission)



Child-Langmuir law (three-halves-power law)

$$\nabla^2 \varphi = -\frac{\rho}{\epsilon_0} \quad \text{1D} \quad \begin{aligned} \varphi(x=0) &= 0 \\ \varphi(x=L_D) &= U_D \\ \left. \frac{d\varphi}{dx} \right|_{x=0} &= 0 \\ v(x=0) &= 0 \end{aligned}$$

$$\rho = \frac{j}{v}$$

$$\frac{1}{2} m v^2 = q_e \varphi \quad \Rightarrow \quad v = \sqrt{\frac{2q_e \varphi}{m}}$$

$$\nabla^2 \varphi = \frac{d}{dx} \frac{d\varphi}{dx} = \frac{j}{\epsilon_0} \sqrt{\frac{m}{2q_e}} \varphi^{-\frac{1}{2}} = \Lambda \varphi^{-\frac{1}{2}}$$

$$\Lambda = \frac{j}{\epsilon_0} \sqrt{\frac{m}{2q_e}}$$

only electrons without collisions

$$L_D = 1 \text{ cm}, U_D = 300 \text{ V}$$

$$j_{C-L} \approx 10 \text{ mA cm}^{-2}$$

$$j_{C-L} = \frac{4}{9} \epsilon_0 \sqrt{\frac{2q_e}{m_e}} \frac{U_D^{\frac{3}{2}}}{L_D^2}$$

\Rightarrow ions play a key role

$$\frac{d\varphi'}{dx} = \Lambda \varphi^{-\frac{1}{2}} \quad \varphi' = \frac{d\varphi}{dx} \quad dx = \frac{d\varphi}{\varphi'}$$

$$\varphi' d\varphi' = \Lambda \varphi^{-\frac{1}{2}} d\varphi$$

$$\frac{1}{2} \varphi'^2 = \Lambda \varphi^{\frac{1}{2}} + K_1 \quad K_1 = 0$$

$$\varphi' = 2 \Lambda^{\frac{1}{2}} \varphi^{\frac{1}{4}}$$

$$\varphi^{-\frac{1}{4}} d\varphi = 2 \Lambda^{\frac{1}{2}} dx$$

$$\frac{2}{3} \varphi^{\frac{3}{4}} = \Lambda^{\frac{1}{2}} x + K_2 \quad K_2 = 0$$

$$\Lambda = \frac{4}{9} U_D^{\frac{3}{2}} L_D^{-2}$$



Arc discharge

The arc is established either by the transition from the glow discharge or by the momentary contact of the electrodes and their subsequent separation.

The cathode fall is in general on the order of the ionization potential for the working gas, or even lower (1–10 V).

The current density at the cathode can range from 100 to 10^7 A cm⁻².

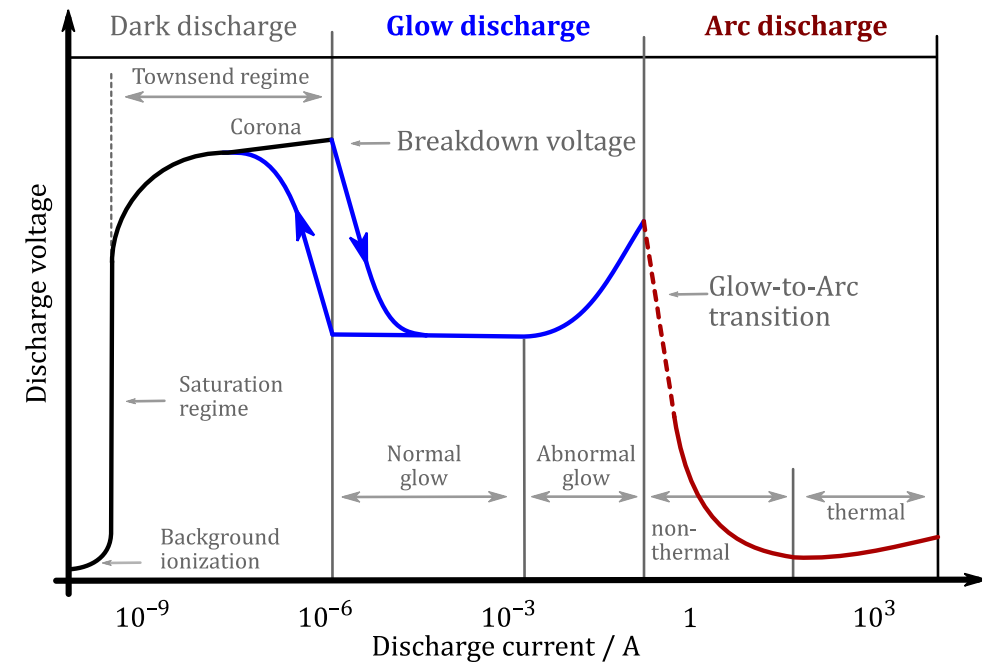
Typical temperature in arcs 1 000 K - 10 000 K up to 20 000 K in arc flash.



AC arc Credit: CC Achgro

Processes of ionization:

electron impact, stepwise ionization
thermal equilibrium (Saha eq.)
photoionization

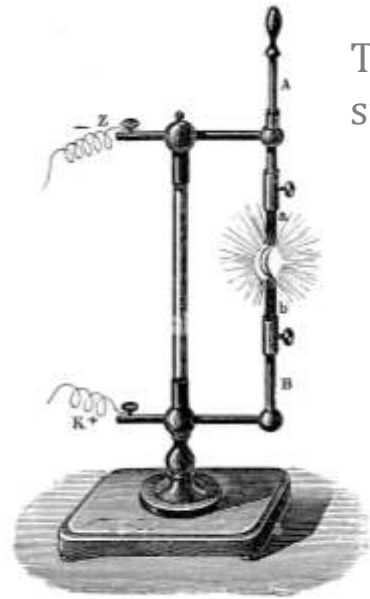




solar.lowtechmagazine.com/2009/01/moonlight-towers-light-pollution-in-the-1800s

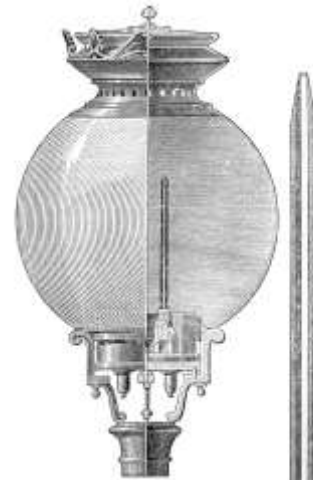
Arc lamps

carbon, tungsten electrodes

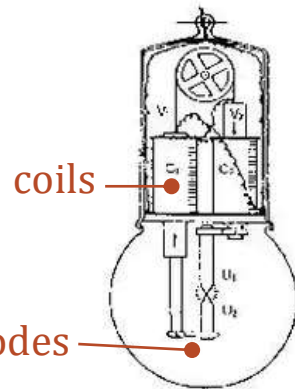


The first arc lamp 1807 arc
sir Humphry Davy

ELECTRIC ARC



Yablochkov candle 1878
≈ 1 hour



Arc lamp with electromagnetic self-adjustment 1881
lasting longer, lower flickering
František Křižík (1847-1941)



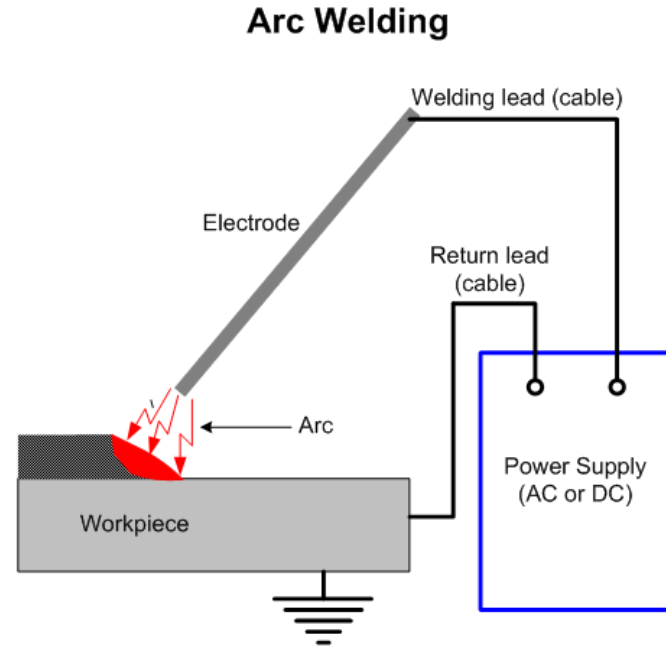
IMAX 15 kW Xe lamp, 25 bar

30 – 60 lm/W

(Incandescent light bulb 16 lm/W)



Arc welding



Credit: CC Substech

The arc parameters strongly depend on the nature and dimensions of the materials.
(Typical MMA “Manual Metal Arc” DC 10 – 50 V, 30 – 200 A)

Arc temperature from 5 000 K – 10 000 K. Iron melts at $\approx 1\,800$ K.



Example of MMA welder with inverter
9 kW, 200 A, 6 kg, 170 EUR



Alternating current discharge

At low frequencies (50 or 60 Hz)
characteristics is similar to a DC discharge

Uniform loading of electrodes

Between cycles, some of the ionized particles remain in the area,
making it easier and more regular to ignite the discharge.



Radio Frequency discharge

low pressure plasma
(no influence of collisions)

$$m_e \frac{d^2 x}{dt^2} = q_e E_0 \cos(2\pi f t)$$

$$v_e = \frac{dx}{dt} = \frac{q_e E_0}{m_e} \frac{\sin(2\pi f t)}{2\pi f} + C$$

$$x = -\frac{q_e E_0}{m_e} \frac{\cos(2\pi f t)}{(2\pi f)^2} + C_2$$

$$\mathcal{E}_{\text{kin}} = \frac{m_e}{2} v_{e\text{max}}^2$$

$$\begin{aligned} f_{\text{RF}} &= 13.56 \text{ MHz} \\ E_0 &= 10 \text{ V cm}^{-1} \end{aligned} \Rightarrow \begin{aligned} \mathcal{E}_{\text{kin}} &\approx 11 \text{ eV} \\ x_{\text{ampl}} &\approx 2.5 \text{ cm} \end{aligned}$$

Acceleration and ionization in collisions

Electron losses:

recombination,
attachment,
diffusion.

Conditions for breakdown

$v_{e\text{max}}$

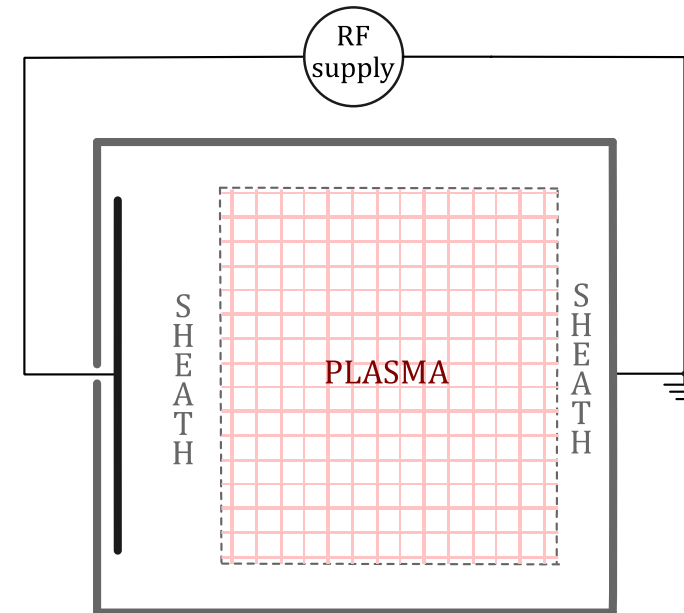
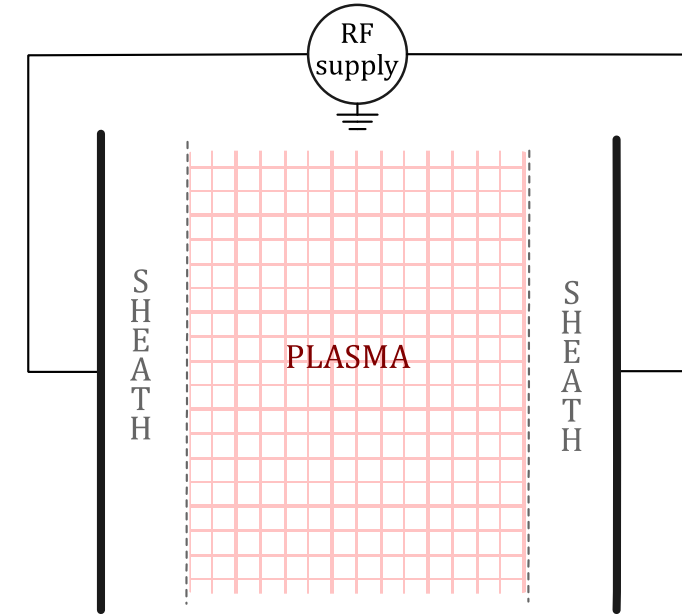
x_{ampl}



Radio Frequency discharge

Frequency bands designated by the ITU for industrial, scientific and medical (ISM) applications

	Center frequency	Bandwidth
	13.56 MHz	14 kHz
RF	27.12 MHz	326 kHz
300 MHz	40.68 MHz	40 kHz
	2.45 GHz	100 MHz
μ W	5.80 GHz	150 MHz
	24.125 GHz	250 MHz



Microwave (μW) discharge

$$v_{e \text{ max}} = \frac{q_e E_0}{m_e} \frac{1}{2\pi f}$$

$$\begin{aligned} f_{\mu\text{W}} &= 2.45 \text{ GHz} \\ E_0 &= 30 \text{ V cm}^{-1} \end{aligned} \Rightarrow \begin{aligned} \mathcal{E}_{\text{kin}} &\approx 30 \text{ meV} \\ x_{\text{ampl}} &\lesssim 3 \text{ }\mu\text{m} \end{aligned}$$

$$\mathcal{E}_{\text{kin}} = \frac{m_e}{2} \left(\frac{q_e E}{m_e} \frac{1}{2\pi f} \right)^2 = \frac{q_e^2 E^2}{8\pi^2 m_e} \frac{1}{f^2}$$

$$\frac{\mathcal{E}_{\text{kin}}}{t} \sim \frac{q_e^2 E_0^2}{m_e} \frac{1}{f_{\mu\text{W}}}$$

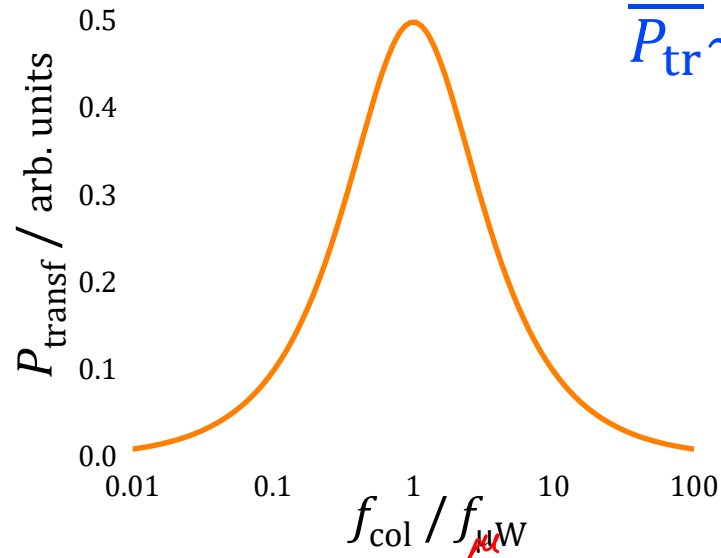
$$\overline{P}_{\text{tr}} \sim \frac{q_e^2 E_0^2}{m_e} \left(\frac{f_{\text{col}}}{f_{\text{col}}^2 + f_{\mu\text{W}}^2} \right)$$

collision plasma

external \vec{B}

$$\overline{P}_{\text{tr}} \sim \frac{q_e^2 E_0^2}{m_e} \left(\frac{f_{\text{col}}}{f_{\text{col}}^2 + (f_{\mu\text{W}}^2 - f_{\text{cycl}}^2)} \right)$$

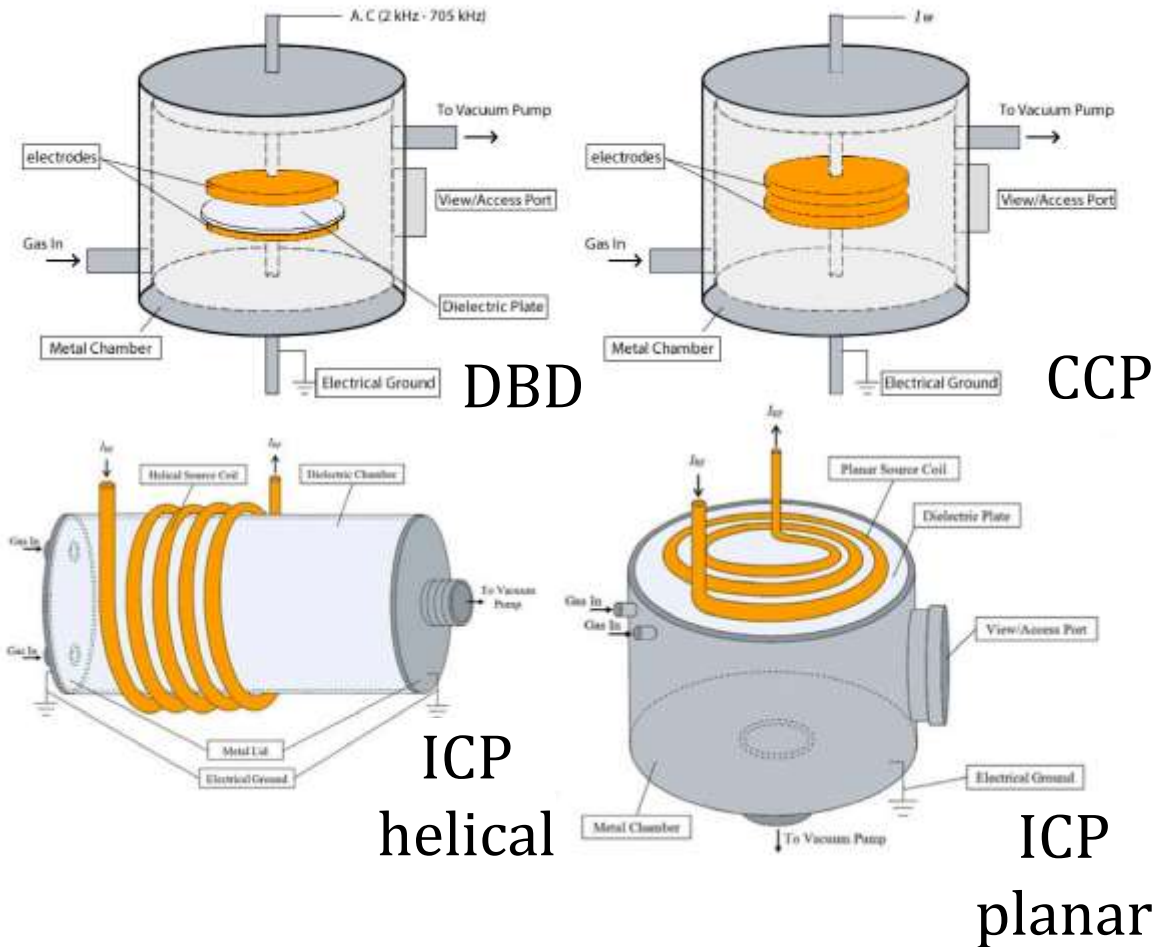
$f_{\text{cycl}} = f_{\mu\text{W}} = 2.45 \text{ GHz}$
for electrons and $B \doteq 88 \text{ mT}$



Capacitively or Inductively Coupled Plasma

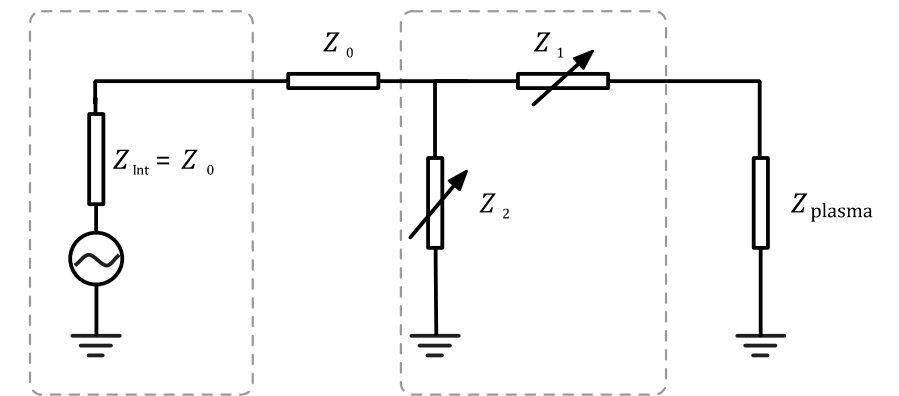
CCP or ICP

Dielectric-barrier discharge (DBD)



RF generator

Matching network



Bacelli G. et al. L-type Matching Network
doi: 10.5220/0001648802020207

Asadian M. et al. *Nanomaterials* 10 (2020) 119.
doi:10.3390/nano10010119



Literature

Chen, Francis F. *Introduction to Plasma Physics and Controlled Fusion*. Cham: Springer International Publishing, 2016.
doi: 10.1007/978-3-319-22309-4.

Inan, Umran S., and Marek Gołkowski. 2010. *Principles of Plasma Physics for Engineers and Scientists*. 1st ed. Vol. 9780521193726. Cambridge: Cambridge University Press. doi: [10.1017/CB09780511761621](https://doi.org/10.1017/CB09780511761621)

Conde, Luis. 2018. *An introduction to plasma physics and its space applications*. Volume 1, Fundamentals and elementary processes. San Rafael [California] (40 Oak Drive, San Rafael, CA, 94903, USA): Morgan & Claypool Publishers.

doi: [10.1088/2053-2571/aae132](https://doi.org/10.1088/2053-2571/aae132)

Chapter 6 The elementary plasma processes

Boulos, M.I., Fauchais, P., Pfender, E. (2016). *Basic Concepts of Plasma Generation*. In: Handbook of Thermal Plasmas. Springer, Cham. doi: 10.1007/978-3-319-12183-3_11-1

Surzhikov, Sergey T. 2012. *Computational Physics of Electric Discharges in Gas Flows*. Vol. 7. Germany: De Gruyter.

doi: [10.1515/9783110270419](https://doi.org/10.1515/9783110270419)

DC discharge

